FORM PTO-1449 Atty. Docket R11.12-0749 09/852/102 LIST OF PATENTS AND PUBLICATIONS FOR First Named Inventor: APPLICANT'S INFORMATION DISCLOSURE STATEMENT Evren Eryurek et al. Filing Date Group Art: May 9, 2001 2857 U.S. PATENT DOCUMENTS Document Examiner Sub Filing Date Initial No. Date Class Name Class If Appropriate AA 3,849,637 11/19/74 Caruso et al. 100 235 297 154 TEV AB 3,952,759 4/27/76 Ottenstein 137 12 MW 700 384 33 205 AC 4,279,013 7/14/81 Cameron et al. MW 700 384 AD 4,417,312 11/22/83 Cronin et al. 282 520 MW ΑE 4,853,693 8/1/89 Eaton-Williams 340 588 MW AF 5,434,774 7/18/95 Seberger 100 364 27 لم 13 TIV 102 364 AG 5,608,650 3/4/97 McClendon et al. 114 520 nw 10<u>432-03</u> 701 384 AH 5,682,317 10/28/97 Keeler et al. TLW ΑI 5,828,567 10/27/98 Eryurok ot al 364 184 ΑJ 8/10/99 5,936,514 Anderson et al. 340 310.01 MW AK 6,023,399 2/8/00 Kogure 361 23 TRW AL700 6,347,252 2/12/02 Behr et al. 3 SRW AM 6,360,277 3/19/02 709 250 Ruckley et al. TRW

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K	JRW	AQ	GB 2,342,453	4/12/00	Great Britain			Х
_	TRW	AR	1 022 626 A2	7/26/00	EP			Х
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

AW International Search Report for International Application Number PCT/US 02/14934, filed May 8, 2002, Search Report dated April 28, 2002

AX International Search Report for International Application Number PCT/US 02/14560,

filed May 8, 2002, Search Report dated September 3, 2002.

EXAMINER: May A Wat DATE CONSIDERED:

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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.